

# AN AB-INITIO-MOTIVATED SCHEME FOR VAN-DER-WAALS ADSORBATE-SURFACE INTERACTIONS: APPLICATION TO TIME-RESOLVED SIMULATIONS OF SOFT, $^4\text{He}$ -DROPLET-ASSISTED, DEPOSITION ON SOLID SURFACES

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The ultra-cold  $^4\text{He}$  droplet-assisted synthesis and deposition of embedded metal nanoparticles (NPs) on solid surfaces, originally proposed by Vilsesov's group [1], attracts nowadays strong attention [1-5]. This is due to both the exciting fundamental physics revealed via the technique, including earlier traces of quantum vorticity in superfluid  $^4\text{He}$  droplets [1,5], and the potential applications in nanoscience and nanotechnology [2,3]. For instance, it can be exploited to induce the formation of ultrathin wires of metal NPs [1,5] with special special electro-, magneto-optical, and catalytic properties. To control the metal NPs film formation, it is important to understand the basic mechanism regulating the  $^4\text{He}$  droplet-mediated deposition of the metal NPs and their subsequent diffusion and aggregation. Of course, this process is much influenced by the specific He-metal, He-surface, and surface-metal interactions so that their accurate descriptions is a prerequisite for realistic first-principles simulations. The first focus of this talk will be on an ab-initio-grounded scheme to van der Waals-dominated adsorbate-surface interactions [6-9,11], with application to the He-surface [7,8,11] and silver-surface systems [9]. Next, we will discuss the dispersionless and dispersion-accounting (time-dependent) density functional and molecular dynamics simulations of  $^4\text{He}$  droplets at impact with graphene and  $\text{TiO}_2(110)$  surfaces [8,10,11]. Finally, theoretical evidences for the  $^4\text{He}$  droplet-assisted-sticking of an embedded metal atom at very low landing energies will be presented [11] (see figure).

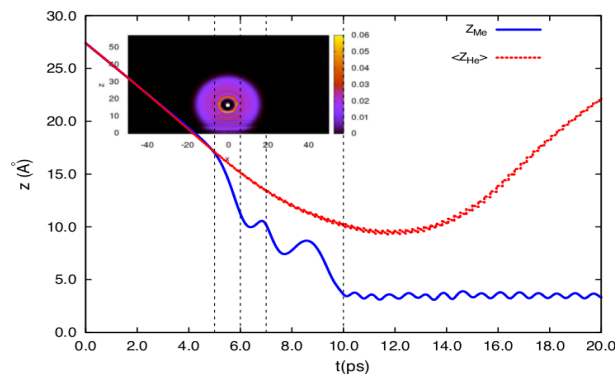


Figure illustrating the  $^4\text{He}$ -droplet-assisted sticking of a metal atom to a solid surface at very low landing energy. Red and blue lines indicate the position (distance to the surface) of the metal atom and the  $^4\text{He}$  droplet mass-center as a function of time, respectively.

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